



RD51 WORKING GROUP 1/TASK 1 MEETING

Large area MPGDs

A LARGE AREA GEM DETECTOR

Serge Duarte
Pinto

Activities

TOTEM

T1 upgrade

Challenges

Single mask technique

Manufacturing

Performance

GEM splicing

Coverlay

Test

Manufacturing

Framing &
honeycomb

Cathode & assembly

High voltage

Prototype

The detector

Gain

What we (can) do to advance with large area detectors

- This meeting, *and next one end of April?*
- GEM detector design & assembly training session, 16–20 February 2009
 - One day lectures by various experienced people
 - Two days hands-on LHCb GEM detector assembly training
 - Two days hands-on GDD-group GEM detector assembly
- One of the lectures will be a crash course readout board design by Rui. This will be equally relevant for non-GEM communities, and will therefore be EVO-cast
- A few groups are having a regular “large area GEM meeting” every few weeks. Something similar is going on for thickGEMs. How about micromegas...?



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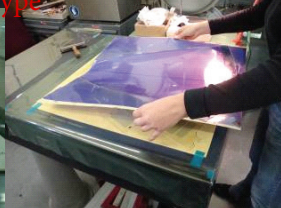
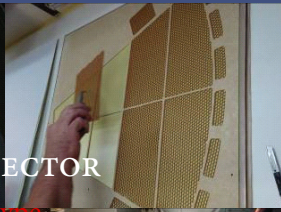
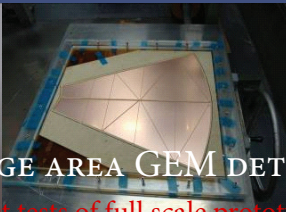
Cathode & assembly

High voltage

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A LARGE AREA GEM DETECTOR

First tests of full scale prototype

Serge Duarte Pinto

CERN GDD group

21 January 2009



TOTEM T1 UPGRADE

Based on large GEM chambers

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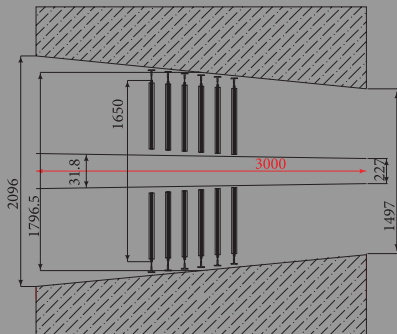
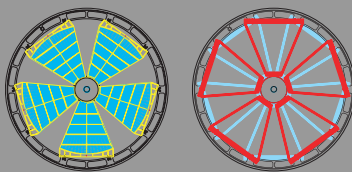
Prototype

The detector

Gain

Ideas for upgrade of TOTEM T1

- Large triple GEM chambers ($\sim 2000 \text{ cm}^2$)
- Discs of 2×5 chambers, back to back
- Overlap allows adjustable disc radius





TOTEM T1 UPGRADE

Technical challenges for such large active area

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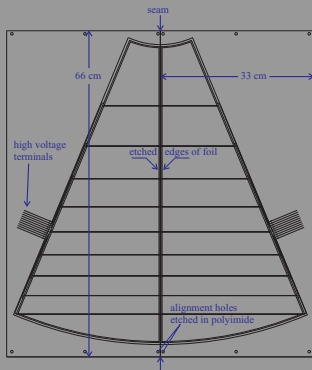
Prototype

The detector

Gain

Technical hurdles for fabrication of large GEMs

- Double mask technique introduces alignment errors at such dimensions
- Base material is only 457 mm wide





TOTEM T1 UPGRADE

Technical challenges for such large active area

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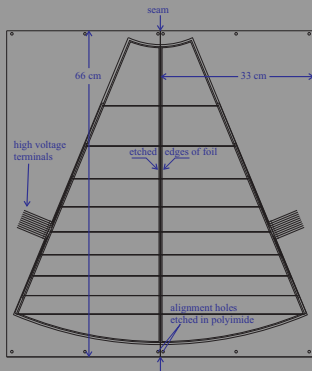
Prototype

The detector

Gain

Technical hurdles for fabrication of large GEMs

- Double mask technique introduces alignment errors at such dimensions → *use single mask technique*
- Base material is only 457 mm wide





TOTEM T1 UPGRADE

Technical challenges for such large active area

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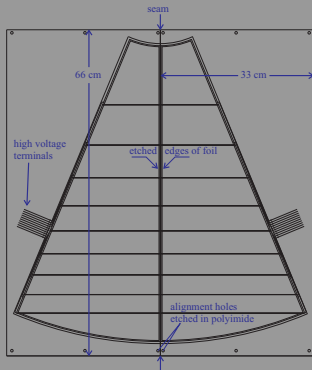
Prototype

The detector

Gain

Technical hurdles for fabrication of large GEMs

- Double mask technique introduces alignment errors at such dimensions → *use single mask technique*
- Base material is only 457 mm wide → *splice foils together*





GEM MANUFACTURING

Double mask vs. single mask technique

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DOUBLE MASK



50 μm kapton foil
5 μm copperclad

photoresist coating,
masking, exposure

metal etching

kapton etching

metal etching

second masking

metal etching,
and cleaning

SINGLE MASK





SINGLE MASK TECHNIQUE

Similar performance at lower cost

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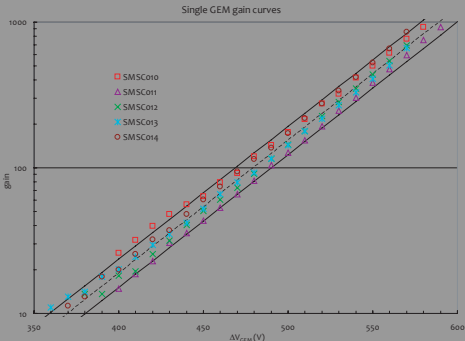
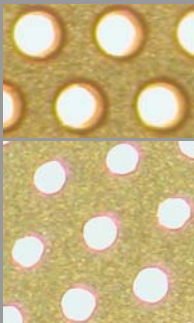
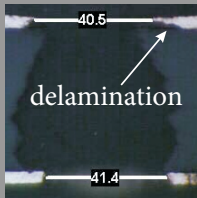
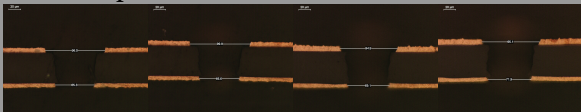
High voltage

Prototype

The detector

Gain

First results were not encouraging →
SMT now performs similar to standard GEM.





SINGLE MASK TECHNIQUE

Rate capability and charging-up of tripleGEM

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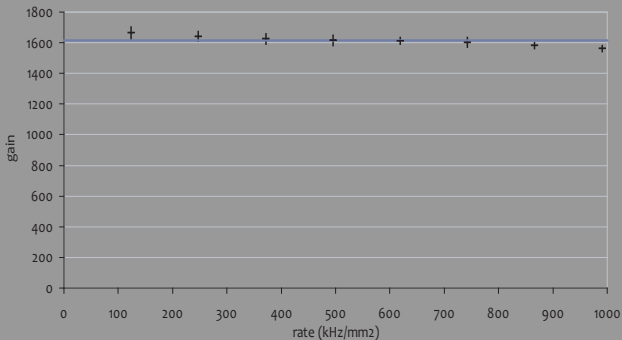
High voltage

Prototype

The detector

Gain

Rate capability with copper X-ray



- Multiply by 320 for rate of primaries
- Charging up is stronger but very fast (seconds)
- Needs to be studied, and can still be improved by optimizing hole profile on new foils



SPLICING GEMs

Glue foils with pyralux coverlay

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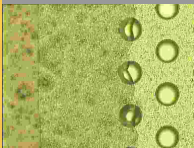
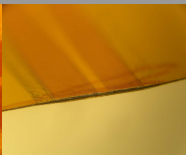
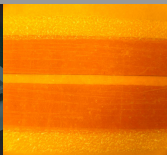
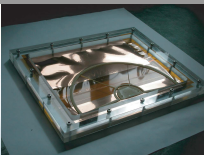
Coverlay
Test

Manufacturing

Framing &
honeycomb
Cathode & assembly
High voltage

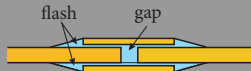
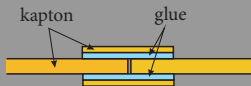
Prototype

The detector
Gain



Coverlay to glue GEMs

Seam is flat, regular,
mechanically and dielectrically
strong, and only 2 mm wide.





SPLICING GEMs

Test performance near the seam

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T₁ upgrade

Challenges

Single mask
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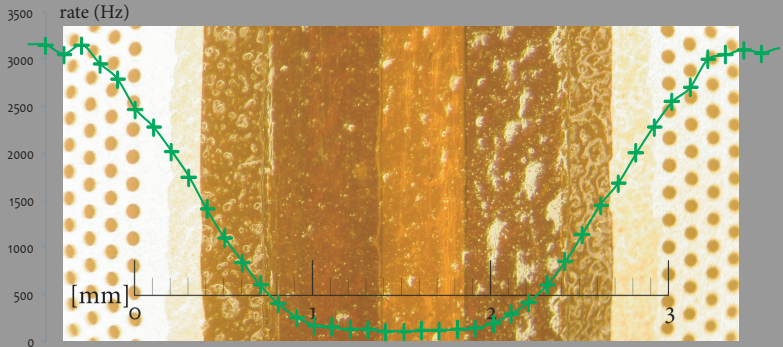
High voltage

Prototype

The detector

Gain

- X-ray with $\varnothing 0.5$ mm collimator
- Rate scan over the seam
- Behaves normally until at the seam
- Performance rest of GEM surface unaffected





MANUFACTURING

From the design to a prototype

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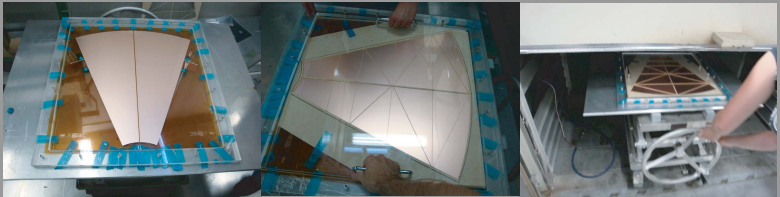
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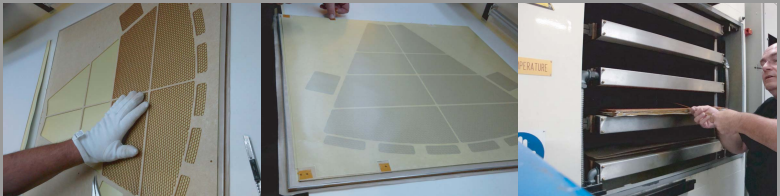
The detector

Gain

Stretching and framing the spliced single mask GEM foils



Making the honeycomb base plane and top cover





MANUFACTURING

From the design to a prototype

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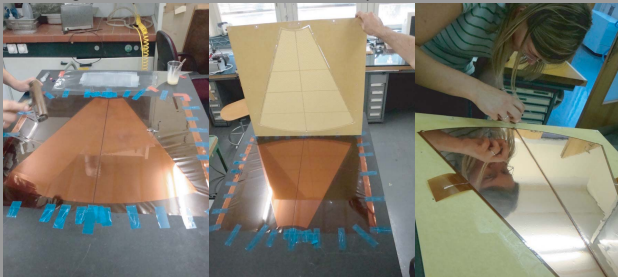
Framing &
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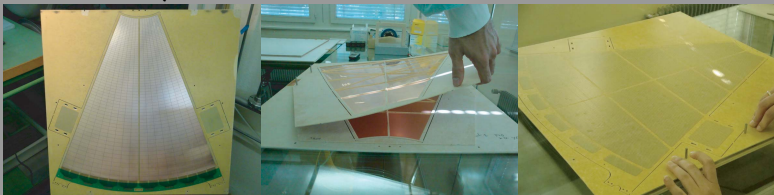
Prototype

The detector
Gain

Gluing the cathode to the honeycomb frame



Final assembly of all frames





MANUFACTURING

High voltage distribution

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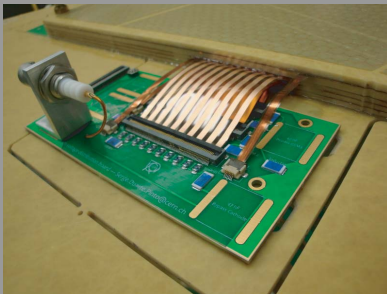
High voltage

Prototype

The detector

Gain

Compact high voltage divider board



- Based on only SMD components
- Using ZIF sockets to connect to GEM terminals
- Traces that lead to GEM sectors are embedded in frame
- Easy to make, and to replace or debug



THE PROTOTYPE

The final detector and its performance

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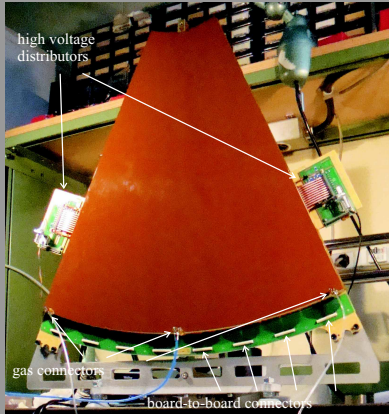
Coverlay
Test

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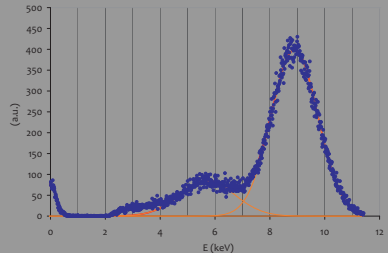
Framing &
honeycomb
Cathode & assembly
High voltage

Prototype

The detector
Gain



- Gas tightness & high voltage stability Ok
- Too late for testbeam by lack of electronics
- $\frac{\sigma_E}{E} = 9.5\%$ measured with Cu X-ray (8.9 keV)





THE PROTOTYPE

The final detector and its performance

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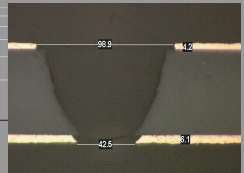
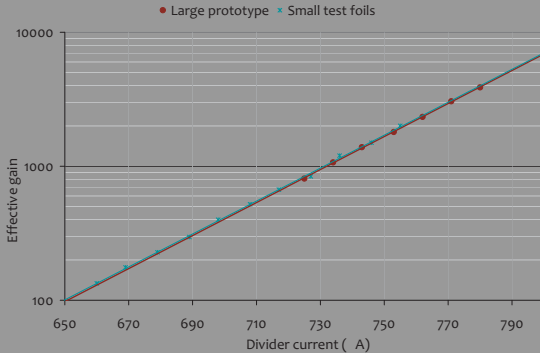
High voltage

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The detector

Gain

Gain consistent with 10 × 10 cm test foils



- Lower gain at equal voltage than standard (double mask) GEM, as expected from wide hole diameter
- Development of optimal hole profile still continues



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Conclusions

- Single mask technique proved viable and cheap alternative
- Splicing method goes beyond limits of base material
- These techniques open the way for large area GEMS

Perspectives

- Connect to fast electronics (VFAT or GP5/7) to study efficiency
- Discharge studies
- Test gain homogeneity
- Charging-up studies of single-, double- and tripleGEM
- Pursue optimization of SMT (steeper holes, smaller rim)

already many foils waiting to be tested ...



EMBEDDED RESISTORS

Screen-printed PTF resistors to be glued in the frame

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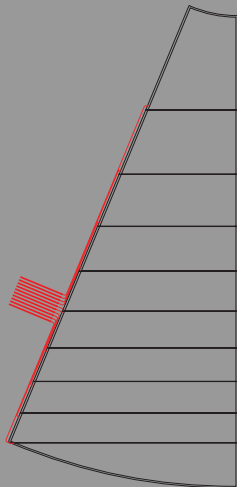
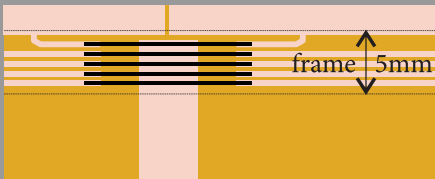
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- A half T₁ GEM foil requires 10 sectors
- Makes 60 sectors per chamber, complicates HV circuitry
- Embedding resistors in frame would solve the issue
- Tolerance requirements for resistors extremely low, but still waiting for suitable high-resistivity paste





SHIELDING OF GEM CHAMBER

Using decoupling capacitors

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Use bottom electrodes as shield by applying decoupling capacitors

- Simulations indicate negligible effect on discharges
- HV distribution boards of prototype have features to implement these capacitors
- must be tested with fast electronics to verify suppression of noise

